

by S. Camillo

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(FILE 'HOME' ENTERED AT 10:00:20 ON 01 NOV 2001)

FILE 'USPATFULL' ENTERED AT 10:01:28 ON 01 NOV 2001

SET ABBREV ON  
SET PLURAL ON

L1 102288 SEA ABB=ON PLU=ON (REMOV? OR ELIMINAT? OR DISSOLV? OR  
DISSOLUT? OR STRIP? OR ETCH?) (10A) (ORGANIC?)

L2 402041 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? OR CARBONATE?)

L3 22378 SEA ABB=ON PLU=ON L1 (P) L2  
L4 55 SEA ABB=ON PLU=ON L3 (P) (WAFER OR SEMICONDUCTOR?)  
D L4, 1-55, TI  
D L4, 1, 53, BIB, AB, KWIC

L5 16302 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? ) (P) (SCAVENGER? OR ADDITIVE?)

L6 3160 SEA ABB=ON PLU=ON L5 AND L1  
L7 301 SEA ABB=ON PLU=ON L5 (P) L1  
L8 31 SEA ABB=ON PLU=ON L7 AND (WAFER? OR SEMICONDUCTOR?)  
D L8, 1-31, TI  
D L8, 5, BIB, AB, KWIC

L9 30846 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? OR BICARBONATE? OR CARBONATE) (P) (SCAVENGER? OR  
ADDITIVE?)

L10 391 SEA ABB=ON PLU=ON L9 (P) L1  
L11 43 SEA ABB=ON PLU=ON L10 AND (WAFER? OR SEMICONDUCTOR?)  
D L11, 1-43, TI  
D L11, 6, BIB, AB, KWIC

L12 23734 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? OR BICARBONATE? OR CARBONATE) (P) L1

L13 1190 SEA ABB=ON PLU=ON L12 AND (SCAVENGER?)  
L14 93 SEA ABB=ON PLU=ON L13 AND (WAFER? OR SEMICONDUCTOR?)  
D L14, 1-93, TI

L15 30846 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? OR BICARBONATE? OR CARBONATE) (P) (SCAVENGER? OR  
ADDITIVE?)

L16 80 SEA ABB=ON PLU=ON L15 (P) (WAFER? OR SEMICONDUCTOR?)  
L17 29 SEA ABB=ON PLU=ON L16 AND L1  
D L17, 1-29, TI  
D L17, 11, BIB, AB, KWIC

L18 1074 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE? OR BICARBONATE? OR CARBONATE) (10A) (SCAVENGER?)

L19 181 SEA ABB=ON PLU=ON L18 AND (SEMICONDUCTOR? OR WAFER?)  
L20 6 SEA ABB=ON PLU=ON L18 (P) (SEMICONDUCTOR? OR WAFER?)  
D L20, 1-6, TI  
D L20, 5, KWIC

L21 260 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE?) (10A) (SCAVENGER?)

L22 23 SEA ABB=ON PLU=ON L21 AND (SEMICONDUCTOR? OR WAFER?)  
D L22, 1-23, TI

D L22, 8 TI  
D L22, 1 KWIC  
L23 1481 SEA [REDACTED] ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE?) (P) (SCAVENGER?)  
L24 398 SEA ABB=ON PLU=ON L23 AND L1  
L25 39 SEA ABB=ON PLU=ON L23 (P) L1  
D L25, 1-39, TI  
D L25, 18, BIB, AB, KWIC  
D L24, 1-398, TI  
L26 196 SEA ABB=ON PLU=ON L1 (P) (SCAVENGER?)  
L27 10 SEA ABB=ON PLU=ON L26 AND (SEMICONDUCTOR? OR WAFER?)  
D L27, 1-10, TI  
D L27, 9, BIB, AB, KWIC  
L28 326119 SEA ABB=ON PLU=ON (ACETIC? OR "CH3COOH" OR "CH.SUB.3COOH"  
OR  
ACETATE?)  
L29 143 SEA ABB=ON PLU=ON L26 AND L28  
L30 39 SEA ABB=ON PLU=ON L26 (P) L28  
D L30, 1-39, TI

13651 USPATFULL  
TI Polymeric etch resist strippers and method of using same  
IN Schevey, William R., Hawley, PA, United States  
IN Kremers, Frank J., Jordan, NY, United States  
PA Allied Chemical Corporation, New York, NY, United States (U.S.  
corporation)  
PI US 3871929 19750318  
AI US 1974-438127 19740130 (5)  
DT Utility  
FS Granted  
EXNAM Primary Examiner: Powell, William A.  
LREP Friedenson, Jay P., Dunn, Michael L.  
CLMN Number of Claims: 17  
ECL Exemplary Claim: 1  
DRWN No Drawings  
LN.CNT 223

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB **Strippers for removal of organic films and**  
deposits, such as polymeric **etch** resists employed in the  
manufacture of **semiconductors** and microcircuits, comprising a  
surface active agent, phenol or **acetic** acid, phenol sulfonic  
acid and chlorinated hydrocarbon.  
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deposits, such as polymeric **etch** resists employed in the  
manufacture of **semiconductors** and microcircuits, comprising a  
surface active agent, phenol or **acetic** acid, phenol sulfonic  
acid and chlorinated hydrocarbon.  
SUMM A class of compositions useful for **removing organic**  
polymeric deposits from the surface of materials used in the  
manufacture  
of